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(74) Agent: DAVIES, Philip; QinetiQ Limited, Intellectual Property, Cody Technology Park, Ively Road, Farnborough, Hants GU14 0LX (GB).

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(71) Applicant (for all designated States except US): **QINETIQ LIMITED [GB/GB]**; Registered Office, 85 Buckingham Gate, London SW1E 6PD (GB).

(72) Inventors; and

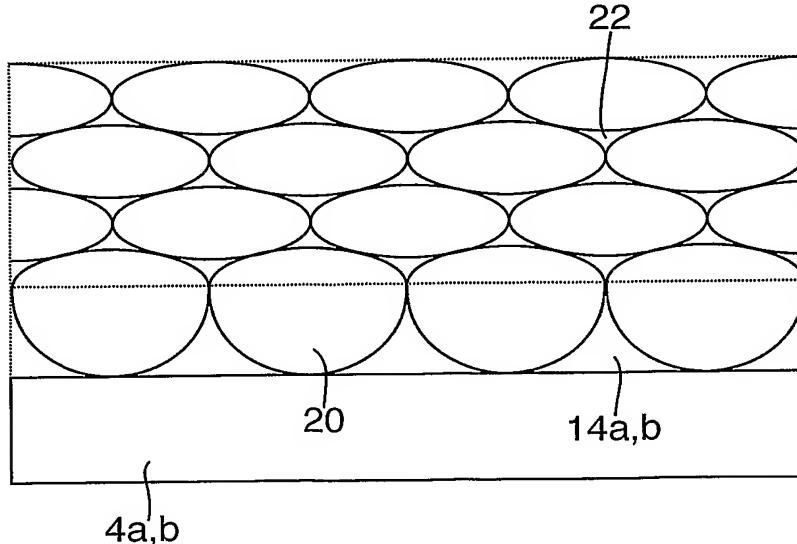
(75) Inventors/Applicants (for US only): **MILLER, Richard, Jonathan [GB/GB]**; Qinetiq Limited, Malvern Technology Centre, Bldg E Room 819, St Andrews Road, Malvern, Worcs WR14 3PS (GB). **VOTTE, Isabelle, Marianne [FR/GB]**; Qinetiq Limited, Malvern Technology Centre, Bldg E Road 912, St Andrews Road, Malvern, Worcs WR14 3PS (GB).

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(54) Title: PHORETIC CELL



(57) Abstract: A relief structure alignment layer (14a,b) comprising a relief structure surface (22) incorporating at least one indentation (20), the at least one indentation (20) having an internal surface extending from the relief structure surface, wherein the relief structure alignment layer has a surface memory alignment layer arranged to impart a preferred liquid crystal director alignment to a liquid-crystal material in contact therewith. A method for configuring a liquid crystal material within a cell having a relief structure alignment layer by applying at least one of an electric field and a magnetic field. A phoretic display comprising at least one relief structure alignment layer.

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